

# Linearity and Dynamic Range of Carbon Nanotube Field-Effect Transistors

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**Abstract** — We examine the problem of optimizing the linearity and dynamic range of a FET device, with application to carbon-nanotube (CNT) FETs. To develop insight into the way FET parameters affect linearity, we derive expressions for noise figure, intermodulation distortion, and dynamic range of a FET described by a unilateral equivalent circuit. This exercise identifies criteria for optimizing linearity and comparing the linearity of dissimilar devices. Measurements prove that CNT devices are significantly more linear than modern microwave FETs.

**Index Terms** — Intermodulation distortion, FET linearity, carbon nanotubes.

## I. INTRODUCTION

Carbon nanotube (CNT) FETs offer exciting possibilities for high-performance nanoscale circuits [1]. Models and measurements of those devices have indicated the possibility of highly linear operation [2, 3], which could significantly improve the dynamic range of many kinds of components and systems.

Perhaps surprisingly, in view of the maturity of nonlinear circuit theory, clear methods for defining and evaluating linearity have never been developed, and many ordinary criteria that purport to describe linearity are often inadequate. In particular, input and output intercept points alone are poor figures of merit for linearity, and popular ideas about optimizing linearity, based on them, are frequently incorrect. Instead, we view the optimization of dynamic range, within noise-figure constraints, as our criterion for linearity. Indeed, optimizing dynamic range is invariably the goal when linearity is considered in the design of a system or component.

To develop an intuitive understanding of linearity criteria, and to make valid comparisons between dissimilar devices, we calculate noise and distortion properties of a simple, unilateral FET equivalent circuit. This provides valuable insight that is not obtainable from more complex numerical approaches.

With this approach, we develop a deeper understanding of device characteristics that affect linearity, how to optimize linearity, and ways to optimize dynamic range. We also develop ways to compare the linearity of dissimilar devices, and we apply those methods to pHEMT and CNT devices.

## II. GAIN AND INTERMODULATION DISTORTION

The analysis of a simplified FET equivalent circuit, shown in Fig. 1 provides considerable insight into the linearity and dynamic range of a CNT FET circuit. Reference [4] includes an analysis of the circuit in Fig. 1 under the assumption that the drain-to-source resistance,  $R_o$ , is infinite. This is clearly not the case in CNT FETs, which invariably have low  $R_o$ , caused by the presence of metallic tubes in the channel. When finite

$R_o$  is included, the expression for third-order IM, the output power  $PIM_3$ , of the  $2\omega_2 - \omega_1$  tone, is

$$PIM_3 = 144a_3^2 |H(\omega)|^6 R_s C_r R_L P_{av} \quad (1)$$

The linear transducer gain is

$$G_t = \frac{P_{LIN}}{P_{av}} = 4a_1^2 |H(\omega)|^2 R_s C_r R_L \quad (2)$$

where  $P_{LIN}$  is the linear output power,  $P_{av}$  is the available input power, and  $R_s$  and  $R_L$  are the source and load resistances, respectively. The  $a_n$  coefficients are those of a Taylor-series expansion of the gate-to-drain  $I/V$  characteristic in the vicinity of the bias point:

$$f(v_g) = a_1 v_g + a_2 v_g^2 + a_3 v_g^3 \quad (3)$$

where  $v_g$  is the gate-voltage deviation around the bias point. The quantity  $C_r$  is the voltage-divider ratio at the output,  $R_o/(R_L + R_o)$ , and  $H(\omega)$  is the transfer function between the source voltage,  $V_s$ , and the internal gate-source voltage,  $V_g$ ;  $H(\omega) = ((R_i + R_s)C_g j\omega)^{-1}$ .

We assume that the input is *tuned*, so  $LC\omega^2 = 1$ , but not necessarily *matched*, so  $R_i$  and  $R_s$  are not, in general, equal. When the output intercept points derived in [4] are modified for finite  $R_o$ , we obtain the third-order output intercept point,  $IP_{o3}$ , in watts, for the  $2\omega_2 - \omega_1$  tone,

$$IP_{o3} = \frac{2}{3} \left| \frac{a_1^3}{a_3} \right| C_r^2 R_L \quad (4)$$

The third-order input intercept point,  $IP_{i3}$ , is simply the output intercept point divided by the transducer gain (2). Thus,

$$IP_{i3} = \frac{1}{6} \left| \frac{a_1}{a_3} \right| \frac{1}{R_s |H(\omega)|^2} \quad (5)$$

The absolute value sign is needed because the quantities  $a_2$ ,  $a_3$  are sometimes negative.

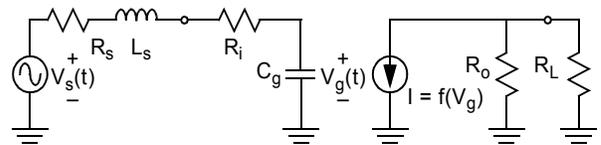


Fig. 1. Simplified pseudolinear small-signal equivalent circuit of a FET. The  $I/V$  characteristic,  $f(v_g)$ , is given by a Taylor-series polynomial in the vicinity of the gate bias point.

### III. NOISE

We assume the existence of two noise sources in Fig. 1: the thermal noise of the resistance in the input loop,  $R_i$ , and a current noise source in parallel with the channel, which comprises the channel noise and the thermal noise of  $R_o$ . This noise model is similar to that of Pospieszalski [6]. From [5], the equivalent input noise temperature,  $T_n$ , is

$$T_n = T_0 \left( \frac{R_i}{R_s} + \frac{G_{nd}}{a_1^2 |H(\omega)|^2 R_s} \right) \quad (6)$$

$G_{nd}$  is the noise conductance of the channel noise source:

$$G_{nd} = \frac{\overline{|i|^2}}{4KT_0B} + \frac{1}{R_o} \quad (7)$$

In (7),  $\overline{|i|^2}$  is the mean-square value of the channel noise current,  $K$  is Boltzmann's constant,  $1.37 \cdot 10^{-23}$  J / K, and  $T_0$  is the standard temperature of 290K. Eq. (6) is derived under tuned but unmatched conditions.

From (6), achieving a low noise figure requires that  $|H(\omega)|$  be maximized by minimizing  $R_i$  and  $C_g$ , but the situation involving  $R_s$  is more complex. At low frequencies the  $R_i / R_s$  term in (6) dominates, and the optimum value of  $R_s$  is relatively large. As frequency increases, however, the optimum value of  $R_s$  decreases, approaching  $R_i$ .

### IV. LINEARITY CRITERIA

#### A. Intermodulation Intercept Points

A number of criteria for evaluating linearity are in regular use. The most common,  $IP_{03}$ , is, by itself, a poor figure of merit for linearity. To illustrate why, consider two amplifiers having identical  $IP_{03}$  but different gains. While both have the same IM output level, for a given linear output level, the input-referred intercept point of the high-gain amplifier is much lower, implying less dynamic range. Furthermore, a high value of  $IP_{03}$  does not generally imply wide dynamic range, as any linear gain or loss following the device affects  $IP_{03}$  but does not change the signal-to-IM ratio. This is particularly significant in a CNT device, as its low drain-to-source impedance affects  $IP_{03}$  and gain identically, but not its inherent linearity (which we define later).

Another possible figure of merit is  $IP_{i3}$ . Input IP has the opposite problem: linear input loss increases  $IP_{i3}$ , but it also increases noise figure identically, so it does not affect dynamic range. Indeed, (5) indicates that  $IP_{i3}$  favors low  $|H(\omega)|$ , thus high input loss. High gain and low noise, however, demand high  $|H(\omega)|$ , so using  $IP_{i3}$  as a figure of merit would lead us to favor the worst devices.

#### B. Dynamic Range

In the design of many types of systems, we are concerned with dynamic range, not simply distortion. One common definition of dynamic range states that the minimum input signal level equals the noise in some bandwidth  $B$ ; then, the maximum input signal is that which generates IM power equal to that noise level.

With this definition, the lower limit of the dynamic range,  $P_{min}$ , from (6), is

$$P_{min} = KBT_n = KBT_0 \left( \frac{R_i}{R_s} + \frac{G_{nd}}{a_1^2 |H(\omega)|^2 R_s} \right) \quad (8)$$

The maximum input level,  $P_{max}$ , occurs when the input-referred third-order IM component equals  $P_{min}$ . From (8), (1), and (2), we obtain

$$P_{max} = \frac{1}{R_s} \left( KT_0B \frac{a_1^2}{a_3^2} \frac{R_s}{36|H(\omega)|^4} \left( \frac{R_i}{R_s} + \frac{G_{nd}}{a_1^2 |H(\omega)|^2 R_s} \right) \right)^{1/3} \quad (9)$$

The ratio  $P_{max} / P_{min}$  is the dynamic range,  $DR$ :

$$DR = \left( \frac{1}{KT_0B} \frac{|a_1|}{a_3} \frac{1}{6|H(\omega)|^2} \frac{1}{\left( \frac{R_i}{R_s} + \frac{G_{nd}}{a_1^2 |H(\omega)|^2} \right)} \right)^{2/3} \quad (10)$$

which can also be written

$$DR = \left( \frac{\frac{|a_1|}{a_3} \frac{1}{6|H(\omega)|^2 R_s}}{KBT_n} \right)^{2/3} \quad (11)$$

#### C. Discussion

The effect of  $|H(\omega)|$  in (9-11) seems counterintuitive. In the development of field-effect transistors, every effort is made to minimize  $R_i$  and  $C_g$ , for a given device size, thus maximizing  $|H(\omega)|$ , and we would expect a large  $|H(\omega)|$  to affect all aspects of performance positively. Eqs. (9-11), however, show that this is not the case, and the matter is further complicated by  $R_s$ , whose effect is more complex. We noted earlier that  $R_s$  must be optimized, not minimized, to achieve minimum noise figure; this is consistent with the behavior of real devices. Moreover, the input intercept points increase as  $|H(\omega)|$  decreases, as input loss reduces the voltage across the gate-to-source capacitor. Thus, it should be expected that input intercept points, when used as figures of merit, might seem to improve as the FET's input resistance and capacitance increase.

The  $|H(\omega)|$  dilemma directly affects the optimization of dynamic range. Invariably we do not want to maximize dynamic range blindly, but instead under a noise-figure constraint. That constraint usually states that the noise figure must be minimized or at least must remain below some particular value. Since  $|H(\omega)|$  is constrained by noise-figure requirements, it cannot be freely adjusted to optimize dynamic range.

This leaves us with the quantity  $a_1 / a_3$  as our only degree of freedom to optimize linearity, so we view this as the primary tool to compare the linearity of various devices. For this reason, the next section focusses on measurements of the  $a_n$  of the pHEMT and CNT.

### V. OPTIMIZATION OF DYNAMIC RANGE

Fig. 2 shows the dynamic range at optimum noise figure vs. frequency and scaling. It is noteworthy that, under these conditions, scaling has little effect on dynamic range, a result that conflicts with common expectations. This occurs because the minimum noise temperature increases with  $S$  at close to the same rate as the distortion (numerator) term in (11). The output intercept point  $IP_{3o}$  increases in proportion to  $S$ , as expected from (4), as long as  $R_L$  similarly scales with  $S$ , and for this reason it is commonly assumed that

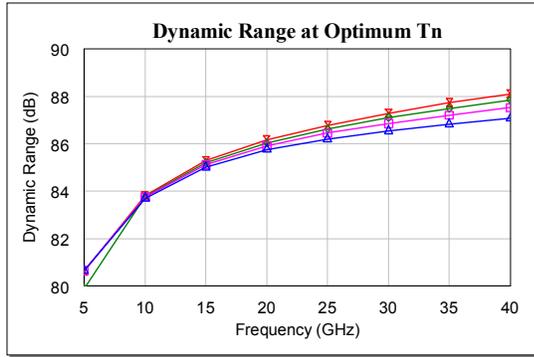


Fig. 2. Dynamic range vs. frequency with  $R_s$  optimized for minimum noise figure at each frequency point, for scaling factors of 0.5( $\Delta$ ), 1.0( $\square$ ), 1.5( $\circ$ ) and 2.0( $\times$ ); also,  $a_1 = 0.20$ ,  $a_3 = 0.10$ , and  $B = 1$  MHz.

dynamic range increases in proportion to  $S$ . These results bring that idea into question.

Fig. 3 shows the dynamic range at 12 GHz as a function of  $R_s$ . The dynamic range increases monotonically with  $R_s$ , although slowly at high  $R_s$  values, because  $|H(\omega)|$  decreases. However, it also decreases the gain and increases the noise figure, again illustrating our earlier point that dynamic range cannot be optimized blindly. Even so, it does contradict the common idea that dynamic range is optimized by conjugate matching the input and output of the device. From Fig. 3, we see that a conjugate input match ( $R_s = R_i = 4\Omega$  when  $S = 1.0$ ) gives poor dynamic range, as it simultaneously increases the noise figure and  $|H(\omega)|$ . Although conjugate-matching the output optimizes  $IP_{o3}$ , from (11) we see that the dynamic range, as defined here, is not affected by output matching. This result underscores, again, the fact that intermodulation intercept points are poor figures of merit for linearity and dynamic range.

## VI. CNT FETs

The CNT FETs have an interdigitated source-drain configuration. The gate has 12 fingers that are 360-nm long and 200  $\mu\text{m}$  wide; the total device periphery is 2,400  $\mu\text{m}$ . The gate fingers have a rectangular cross-sectional profile. The gate is deposited on top of high-K  $\text{Ta}_2\text{O}_5$  dielectric.

The gate-to-source spacing is 0.1  $\mu\text{m}$  and the source-to-drain spacing is 0.7  $\mu\text{m}$ . The source and drain fingers are

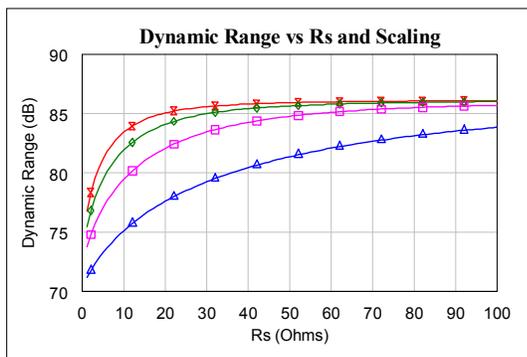


Fig. 3. Dynamic range vs.  $R_s$  at 12 GHz with the same scalings. The device parameters and graph markers are those of Figure 2.

connected in parallel by their respective bus metals; the gate bus connects all gate fingers and overlaps the source bus. The gate bus crosses over the source bus on a 3- $\mu\text{m}$  thick BCB interlayer dielectric.

## VII. DEVICE LINEARITY

In many cases we wish to compare the linearity of dissimilar devices. From (11), we have four terms that determine dynamic range:  $a_1 / a_3$ ,  $|H(\omega)|$ ,  $R_s$ , and  $T_n$  (or  $F$ ). The latter three are constrained by the need to achieve an acceptable noise figure, as is gate-width scaling. This leaves us with  $a_1 / a_3$  as the most important basis for comparing linearity; it is especially useful, as it is an inherent property of a device, largely independent of device width and frequency.

In all cases, devices can be compared on the basis of a noise quantity and a linearity term.  $T_n$  obviously should be that noise quantity, and  $L$ , where

$$L = \left| \frac{a_1}{a_3} \right| \frac{1}{6|H(\omega)|^2 R_s} \quad (12)$$

is the linearity term.

## VIII. MEASUREMENTS OF $a_n$ TERMS

We use an earlier method to measure values of  $a_n$  [7], appropriately updated for devices, such as carbon nanotube FETs, having low drain-to-source resistance. The method consists of exciting the device, in a test fixture, at a frequency low enough that the reactive parasitics are negligible. Harmonics of that excitation are measured at the device output, and the  $a_n$  terms are found from a Volterra analysis.

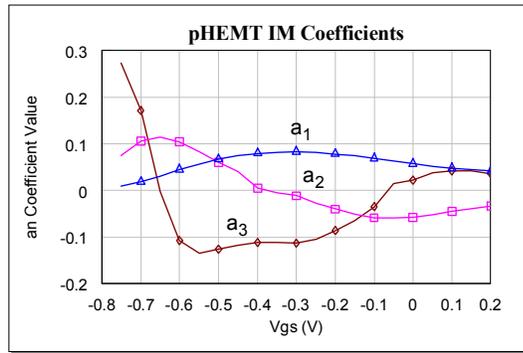
## IX. DEVICE COMPARISON

In this section we compare the  $a_n$  measurements of a modern, conventional pHEMT, the Renesas NE3512, and our CNT device.

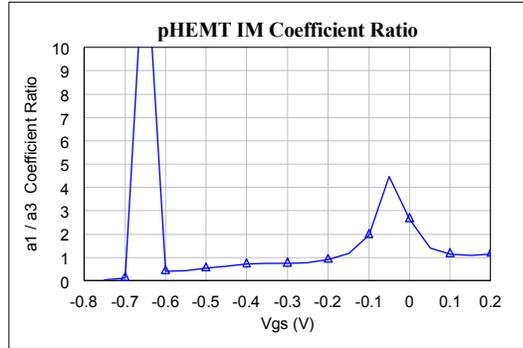
Fig. 4 (a) shows the  $a_n$  values of the HEMT device at a drain bias voltage of 2.5V, and Fig. 4 (b) shows  $a_1 / a_3$ . The behavior is typical of modern FET devices. The pHEMT's  $a_1 / a_3$  peaks at -0.65V or -0.07V exist only in ideally unilateral circuits; in a real amplifier, IM3 components are generated by second-order mixing between first- and second-order voltage components at the gate. This is dominated by  $a_2$ , and since  $a_3 \sim 0$  is the  $a_2$  maximum, those bias points do not result in low distortion. Between those points lies the practical gate bias region, where  $a_1 / a_3$  is a little less than 1.0.

Fig. 5 shows the measured  $a_n$  coefficients of the CNT device and the  $a_1 / a_3$  ratio. These measurements are somewhat less accurate than the pHEMT measurements, as the device is subject to slow drift, on the order of minutes, and fine fluctuations of the gate  $I / V$  characteristic, on the order of seconds. These phenomena are responsible for the variations in the  $a_n$  characteristics above approximately 0.2V.

The behavior of the coefficients for the CNT FET is markedly different from those of the pHEMT device. At gate-bias voltages below zero, the curves are relatively flat and the values  $a_2$  and  $a_3$  are quite small. The  $a_3$  coefficient, in particular, is positive over most of this region, so amplifiers using CNT devices should exhibit modest gain enhancement before saturation. Above zero, the transconductance rolls off and the  $a_3$  coefficient increases significantly. Even in that region, however, the CNT's  $a_1 / a_3$  ratio is greater



(a)



(b)

Fig. 4. (a) Measured  $a_n$  coefficients of an NE3512 FET as a function of gate-bias voltage. (b) The ratio  $a_1 / a_3$ . The peaks are largely fictitious, as they occur at gate voltages near the points where  $a_3 = 0$  (see text).

than the pHEMT's, showing more than an order of magnitude superiority.

From (12), we must consider  $|H(\omega)|$  as well as  $a_1 / a_3$ . The parameters of interest are shown in Table 1., including the

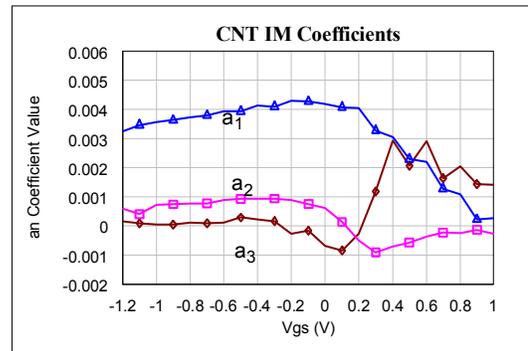
Table 1: FET parameter Comparison

Parameter	NE3512	CNT FET
$R_g (\Omega)$	1.9	1.4
$R_d (\Omega)$	0.8	6.1
$R_s (\Omega)$	1.0	0.47
$C_{gs} (\text{pF})$	0.28	1.95
$ H(\omega)  @ 1 \text{ GHz}$	10.9	1.57
$L (R_s = 50\Omega, f = 1 \text{ GHz})$	$2.6 \cdot 10^{-5}$	0.046

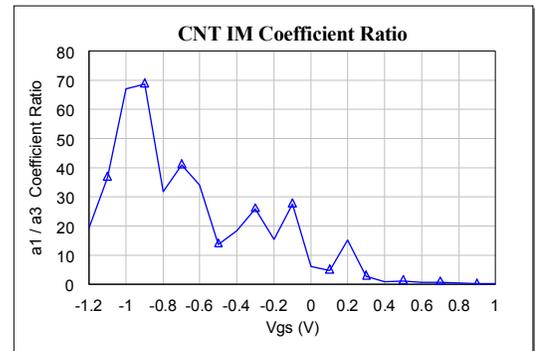
value of  $|H(\omega)|$  with a 50-ohm source. Because of its greater gate-to-source capacitance, the CNT device's  $|H(\omega)|$  is approximately a factor of six smaller than that of the pHEMT, making the linearity term (12)  $\sim 10^3$  that of the pHEMT. It is difficult to estimate the improvement in dynamic range, as noise figure of the CNT device was not measured. However, from (11), the CNT noise temperature would have to be approximately 30 dB greater than that of the pHEMT to have the same dynamic range

## X. CONCLUSIONS

Linearity measurements show that CNT devices have extraordinary inherent linearity, significantly greater than



(a)



(b)

Fig. 5. (a) Measured  $a_n$  coefficients of a CNT FET as a function of gate-bias voltage;  $V_{ds} = 3.3\text{V}$ . (b) The ratio  $a_1 / a_3$ . Values above 0V are affected by drift and small-scale  $I / V$  instability.

that of modern microwave FETs. This result confirms earlier predictions [2, 3].

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